

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Evangelos Gogolides et al.

Application No. 10/516,384

Confirmation No. 4756

Filed: May 30, 2003 (Int'l. Appl. No.
PCT/GR03/00018)

Art Unit: 1795

Examiner: Sin J. Lee

For: Lithographic Materials Based On Polymers
Containing Polyhedral Oligomeric
Silsesquioxanes

**AMENDMENT IN RESPONSE TO
OFFICE ACTION DATED JUNE 3, 2008**

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

In response to the Office Action dated June 3, 2008, please amend the above-identified patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Amendments to the Drawings begin on page 4 of this paper and include an attached replacement sheet.

Remarks/Arguments begin on page 5 of this paper.

I hereby certify that this paper (along with any paper referred to as being attached or enclosed) is being transmitted via the Office electronic filing system in accordance with § 1.6(a)(4).

Dated: September 3, 2008

Signature:  (Andrew M. Lawrence, Reg. No. 46,130)